

Experimental and numerical studies on the proposed application of hollow electron beam collimation for the LHC at CERN

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Personal Introduction



Master thesis 2013 @ CERN & Fermilab



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Introduction & Concept

- Hollow Electron Beam Collimation
- HEBC experience at Tevatron
- Focus of this work

Vince Moens, 11.04.2013

Hollow Electron Beam Collimation

Hollow electron beam studies for LHC collimation part of US-LARP since 2009:

Hollow Electron Beam Collimation is the enhancement of diffusion of halo particles through the use of the transverse electric fields of a hollow electron beam.

- Technique aimed at improving current system (hierarchy remains)
 Fully compatible with present and future systems
- Installation point is flexible



Hollow Electron Beam Collimation Align hollow electron beam coaxial with beam core hollow electron beam 4336 VERTICAL POSITION (mm) Superconducting solenoid protons TEL02 hollow electron beam

Hollow electron beam creates transverse electric field



proton core

HORIZONTAL POSITION (mm)



Gun solenoid

$$r \leq R_o \quad E = 0$$

$$R_i \geq r \leq R_o \quad E(r) \propto r$$

$$R_o \geq r \quad E(r) \propto \frac{1}{r}$$

Collector solenoid

Collector

2690

Tevatron Electron Lens 2



Hollow Electron Beam Collimation

- □ Transverse kick on halo particles with $R_i < r < R_o$ $\Theta = \frac{1}{2\pi\varepsilon_0} \frac{I_r L(1 \pm \beta_e \beta_p)}{r\beta_e \beta_p c^2 (B\rho)_p}$
- Enhances diffusion rate of halo particles -> Deplete tails



Actual cleaning done by standard collimators

- HEBC creates buffer zone between core and collimators
- Control over when tails are cleaned
- HEBC tunes impact parameter slightly

HEBC Experience at the Tevatron

- Approx. 10 years of stable Tevatron Electron Lens operation for abort gap cleaning
- HEBC Experiments at Tevatron from 2010-2011 for LHC collimation studies
- Observations:
 - Effects on beam core were negligible
 - Curcial for luminosity production in the collider
 - Control of scraping of beam halo possible
 - Loss-spike fluctuations due to beam jitter reduced
- Rely on Tevatron experience
- 2 new designs for LHC
 - Implementation studies
 - Conceptual Design Report (November 2013)

Focus of this work

- My task: Characterizes a new 1-inch Hollow Electron Gun (HG1b) for use at LHC (1-1 implementation)
 - Optimal operation parameters
 - Yield studies
 - Beam evolution
 - Transverse fields
- Completed first full 3D simulations of HG1b in Tevatron electron lens test stand
- Input for Conceptual Design Report in November 2013



Electron Gun & Test Stand

- 1 inch Hollow Electron Gun
- **Tevatron Electron Lens Test Stand**
- Thermionic Emission

Vince Moens, 11.04.2013

1 inch Hollow Electron Gun (HG1b)

- Bigger gun for higher beam currents
- Hollow cathode: Tungsten impregnated with 3BaO:1CaO:1Al₂O₃
- $\square \emptyset_{o} = 25.4 \text{ mm}, \emptyset_{i} = 13.5 \text{ mm}$







Tevatron Electron Lens Test Stand (TELTS)

Used for all measurements part of this work

- Data collection:
 - Pinnhole collector
 - Toroids & oscilloscope
- Similar to TEL2
 - No bends
 - No superconducting main solenoid



Main

Small

Solenoids

Solenoid



- Gun 5. Beam tube
- Collector 6. Magnetic Corrector controls

Thermionic Emission



Aim: Operate in Space Charge Limited Emission Regime

- Emission type depends on filament current and cathode potential
- Space Charge Limited Emission: $I_{beam} = PV_a^{\frac{3}{2}} = 1.67 \times 10^{-3} \pi \left(\frac{q}{mc^2}\right)^{\frac{1}{2}} \frac{V_a^{\frac{3}{2}}}{d^2} \left(r_{ext}^2 - r_{int}^2\right) \quad [A]$ Yield measured in perv: $P = \frac{I}{V_a^{\frac{3}{2}}} \quad [perv]$



Results

- Optimal operation parameters for LHC
- Yield measurements
- Beam evolution
- **Rough Upper Estimate of Emittance Growth**
- 3D simulations

Vince Moens, 11.04.2013

Optimal Operating Parameters

- Inner radius 3 σ < R_i < 6 σ (σ = 4.7×10⁻⁴ m)
- □ Magnetic compression ($R_i = 4\sigma$)
 - Factor 11.5
 - B=0.43-5-0.43 T
- Cathode potential of HG1b
 - 3-4 kV for similar current as Tevatron experiments
- Optimal filament current
 - Up to now: 9.25 A
 - □ Can be reduced to \approx 8.5 A



HG1b Yield

- Before transport improvement:
 - □ Yield: 4.22(3)×10⁻⁶ perv
 - Consistent with previous measurements
 - Slow degradation of gun
- Yield at collector 70% of gun
 - Biggest Gun yet!
- After transport improvement:
 - □ Yield: 5.3(1)×10⁻⁶ perv
 - Produces 5 A at 10 kV
 - 15% of SAM simulations
 - 65% more yield than HG06



Transverse Profiles

Current density profiles by moving beam over pinhole \square Profiles sorted by B_{main} and V_{a}

Red lines: scaling lines

Profiles injected into 3D simulation



Beam Scaling

Scaling law angle of rotation must be constant

 $B\propto \sqrt{}$ 8kV@0.4T 7.15e-3 CATHODE POTENTIAL AT B=0.4T SCALING FACTOR [T/V^{0.5}] 6.25kV@0.4T 5.05e-3 3kV@0.4T 4.47e-3 0.24 0.16 0.32 0.40

MAGNETIC FIELD [T]

Rough Emittance Growth Estimates

- Calculation of electric fields using WARP
- Emittance growth given by:

$$\Delta \varepsilon = \beta \theta^2 = \beta \left(\frac{E_{tot} q E_r L}{E_{tot}^2 - E_0^2} \right)^2 \quad \left[\frac{m}{turn} \right]$$

- Rough estimate through mean Gaussian weighted RMS field in center of beam
- □ Current LHC emittance growth rate $\approx 1 \times 10^{-5} \text{ s}^{-1}$

EGR [×]	Cathode Voltage [kV]						
Radius [mm]	\mathbf{B}_{max} [kG]	500	1000	2000	3000		
4σ	4	0.089	0.246	1.11	97.8 (3125 V)		
	3.2	0.025	0.093	29.3	48.7		
	2.4	0.010	4.59	18.9	227		
	2.4	1.34	4.54	144	-		

Indication of no extra emittance growth -> Luminosity



First Full 3D simulations

- First 3D simulation of HEBL using WARP
- Aimed at extracting kick map for SixTrack or Lifetrack×0.00 simulations
- Two injection methods implements
- Issues to be solved:
 - Implementation of TEL2 bends
 - Heavy computing power needed
 - Further diagnostics tools need to be implemented
- Continued by myself for conceptual design report



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Conclusions



Conclusions

- Useful technique for enhancing current collimation systems
 - Active control of losses
 - Less dependent on loss spikes
 - Increases impact parameter
- Determined optimal operating parameters for LHC
 - Factor 11 compression
 - 8.5 A Filament Current
 - 3-4 kV Cathode Potential
- Transmission upgrade through magnetic compression in TELTS
- □ Significant yield improvement of HG1b: 5.3(1)×10⁻⁶ perv
- $\square \text{ Transverse profile scaling } \propto \frac{\sqrt{V_a}}{B}$
- Emittance growth rates are acceptable compared to current growth rates
- First Full 3D simulations

Questions

Thank You!



Availability:

- Fermilab Library: FERMILAB-MASTERS-2013-02 (www.inspirehep.net)
- CERN Library: CERN-THESIS-2013-126 (www.cds.cern.ch)

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HEBL collaborator

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Backup Slides



Backup Contents

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- Tevatron Electron Lens 2

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- Transverse Profiles

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- Derivation Emittance Growth Rate
- WARP Implemented Gun
- WARP Potential Fields
- WARP Electric Fields

LHC & Collimation System

- Beam continually cleaned through multi-stage collimation system
- Approximately 100 collimators
- 4 colliding IR & 4 non interacting IR
- Affected by electromagnetic impedance, beam jitter, increased loss rates when moving collimators

Shower

absorber

halo

Tertiary beam

Arc(s→

+ hadronic

showers

Secondar

collimator

ondarv beam

Primary

Primary

Circulating beam

beam

halo

collimator

halo

+ hadronic

shGleaning

incortion



Tevatron Intensity





Tevatron Electron Lens 2

Gun & collector outside tube

Only one beam

3 main solenoids

Pierce through edge



Conceptual Straight HEBL Design



Thermionic Emission





Cathode Temperature



Time Structures

- Rise Time: 200 ns
- Bunch spacing Tevatron: 400 ns
- Bunch spacing LHC: 25 ns
- Possible to obtain bunch by bunch manipulation in LHC.
- Aim is to obtain turn-by-turn excitation.

Valentina achieved 75% cleaning in 20s using AC beam mode

Generalized Perveance

$$K = \frac{I}{I_0} \frac{2}{(\beta \gamma)^3} (1 - \gamma^2 f_e) \qquad I_0 = \frac{4\pi \varepsilon_0 mc^3}{q} = 17kA$$

$$\beta = \frac{v}{c} \text{ and } v = \left(\frac{2qV}{m}\right)^{\frac{1}{2}}$$
$$K = P \times \left[\frac{(1-\gamma^2 f_e)}{4\pi\varepsilon_0\gamma^3(2q/m)^{1/2}}\right]$$
$$\frac{K}{(1-f_e)} = P \times \left[\frac{m^{1/2}}{4\pi\varepsilon_0(2q)^{1/2}}\right] = P \times 1.515 \times 10^4$$



SAM Simulations



SAM_V4.00 24-01-2012 11:56 b_05kg_135710kv_jan_23_2012

SAM_V4.00 10-01-2012 12:00 jan_09_2012_5kv_adj



B = 0.05 T V=5 kB B = 0.5 T

Background Gases



Background Gas of Test Stand

Hydrogen gas at 1 x 10⁻⁸ mbar

Transverse Profiles

□ V_a = 500 V

- \Box I_{peak} = 73 mA
- □ B = 1 4 1 kG

 \Box V_a = 8 kV

$$I_{peak} = 3.88 \text{ A}$$



Beam Evolution

Angle of rotation around beam axis (derived from dioctron frequency)

$$\varphi = \frac{PE_0 L\sqrt{V_a}}{4\pi\varepsilon_0 ec^2 (R_o^2 - R_i^2)B} \left(1 - \left(\frac{R_i}{r}\right)^2\right) \quad [rad]$$

 \square Dependence on r \rightarrow slippage

Scaling law angle of rotation must be constant

 $B \propto \sqrt{V}$

Angle of rotation at outer cathode radius

Angle of rotation $[^{\circ}]$	Acceleration Potential [kV]							
Magnetic Field [T]	1	2	3	4	5	6	7	8
0.40	72	101	124	143	160	175	189	202
0.32	89	127	155	179	200	219	237	253
0.24	120	169	207	239	267	292	316	337
0.16	179	253	310	358	400	438	473	506

Beam Evolution

Profile evolution with V at B= 0.8-3.2-0.8 kG





Profile evolution with V at B= 0.8-3.2-0.8 kG ^(j)



(a) $B_{main} = 1.6 \text{ kG}$ (b) $B_{main} = 2.4 \text{ kG}$ (c) $B_{main} = 3.2 \text{ kG}$ (d) $B_{main} = 4 \text{ kG}$

Transverse Electric Fields at 500 V

Charge density in x-y plane Electrostatic potential in x-y plane Electrostatic potential in x-y plane 0.010 0.010 0.00035 500 500 0.0003 0.02 0.005 0.005 400 400 0.00025 300 300 0.0002 ≻0.00 ≫.000 ≫.000 0.00015 200 200 0.0001 -0.005 -0.005 100 100 -0.02 5e-05 0 0 -0.010 -0.010 -0.010 0.00 X 0.000 X -0.005 0.000 0.005 0.010 -0.02 0.02 -0.005 0.005 0.010 Х Electric field strength in x-y plane E-field vs X (blue) and Y (red) Electric field strength in x-y plane 0.010 40 40000 40000 0.02 0.005 30 30000 30000 E-field (kV/m) ≻0.00 ≫.000 20000 20000 -0.005 10000 10000 10 -0.02

0.00 X

-0.02

0

-20

X or $\overset{0}{Y}$ (mm)

20

0

0.02

-0.010

-0.010

-0.005

0.000 X

0.005

0.010

Transverse Electric Fields at 8 kV



Derivation – Angle of Rotation

$$\omega_p^2 = \frac{q^2 n}{\varepsilon_0 \gamma^3 m} \left(1 - \gamma^2 f_e \right) \qquad \omega_r = \omega_D = \frac{\omega_p^2}{2\omega_c} = \frac{ne}{2\varepsilon_0 B} \tag{1}$$

$$\omega_r = \omega_D (1 - f - \beta_z^2) \left[1 - \left(\frac{R_i}{r}\right)^2 \right], \quad \forall R_i \le r \le R_o$$
(2)

$$\varphi_r = \frac{\omega_D L}{v_z} \left[1 - \left(\frac{R_i}{r}\right)^2 \right] = \frac{n_e e L}{2\varepsilon_0 B v_z} \left[1 - \left(\frac{R_i}{r}\right)^2 \right], \quad \forall R_i \le r \le R_o \tag{3}$$
$$IL \qquad \left[1 - \left(\frac{R_i}{r}\right)^2 \right]$$

$$\varphi_r = \frac{\Pi L}{2\pi\varepsilon_0 B(R_0^2 - R_i^2)v_z^2} \left[1 - \left(\frac{\kappa_i}{r}\right) \right]$$
(4)

$$=\frac{IL}{2\pi\varepsilon_0 B(R_0^2-R_i^2)c^2eV_a\left(\frac{(2E_0+eV_a)}{(E_0+eV_a)^2}\right)}\left[1-\left(\frac{R_i}{r}\right)^2\right],\quad\forall R_i\leq r\leq R_o\quad(5)$$

$$\varphi = \frac{IE_0L}{2\pi\varepsilon_0 B(R_0^2 - R_i^2)2c^2 eV_a} \left[1 - \left(\frac{R_i}{r}\right)^2 \right], \quad \forall R_i \le r \le R_o$$
(6)

$$\varphi = \frac{PE_0L}{4\pi\varepsilon_0 c^2 (R_0^2 - R_i^2)e} \times \frac{\sqrt{V_a}}{B} \left[1 - \left(\frac{R_i}{r}\right)^2 \right]$$
(7)

$$= 2.7 \times 10^{-2} \frac{\sqrt{V_a}}{B} \left[1 - \left(\frac{R_i}{r}\right)^2 \right], \quad \forall R_i \le r \le R_o$$
(8)

Derivation – Electric Field Equations

$$\oint _{\partial\Omega} E \cdot dS = \frac{Q_{\text{encl},\Omega}}{\varepsilon_0} \tag{1}$$

$$E \cdot 2\pi r L = \frac{\int_0^R \rho(r') 2\pi r' L dr'}{\varepsilon_0} \tag{2}$$

$$E = \frac{\int_0^R \rho(r') r' dr'}{\varepsilon_0 r} \tag{3}$$

$$r \leq R_{o} \qquad E = 0 \qquad (4)$$

$$R_{i} \geq r \leq R_{o} \qquad E(r) = \frac{\rho(r^{2} - R_{i}^{2})}{2\varepsilon_{0}r} = \frac{IL(r^{2} - R_{i}^{2})}{2\pi v_{z}\varepsilon_{0}r(R_{o}^{2} - R_{i}^{2})} \qquad (5)$$

$$R_{o} \geq r \qquad E(r) = \frac{\rho(R_{o}^{2} - R_{i}^{2})}{2\pi\varepsilon_{0}r} = \frac{IL}{2\pi v_{z}\varepsilon_{0}r} \qquad (6)$$

Derivation – Emittance Growth Rate

$$\frac{\mathrm{d}}{\mathrm{d}t}p_r = F_y = q\vec{E}_r \tag{1}$$

$$p_r = q\vec{E}_r t \tag{2}$$

$$p_{z} \tan(\theta) = q\vec{E}_{r}$$

$$\rightarrow \tan(\theta) = \frac{q\vec{E}_{r}t}{p_{z}}$$

$$\rightarrow \tan(\theta) = \frac{q\vec{E}_{r}L}{p_{z}v_{z}}$$

$$\rightarrow \tan(\theta) = \frac{\gamma E_{0}q\vec{E}_{r}L}{p_{z}^{2}}$$

$$\rightarrow \tan(\theta) = \frac{E_{tot}q\vec{E}_{r}L}{(E_{tot}^{2} - E_{0}^{2})}$$

$$\Rightarrow \vartheta = \frac{E_{tot}qE_{r}L}{E_{tot}^{2} - E_{0}^{2}}$$

(3)

(4)

(5)

(6)

(7)

(8)

Derivation – Emittance Growth Rate

$$\begin{pmatrix} x_{n+1} \\ x'_{n+1} \end{pmatrix} = M \begin{pmatrix} x_n \\ x'_n \end{pmatrix}$$
(1)

$$\varepsilon = \gamma x_{n+1}^2 + 2\alpha x_{n+1} x_{n+1}' + \beta x_{n+1}'^2 = \gamma x_n^2 + 2\alpha x_n x_n' + \beta x_n'^2$$
(2)

$$\begin{pmatrix} \tilde{x}_{n+1} \\ \tilde{x}'_{n+1} \end{pmatrix} = M \begin{pmatrix} x_n \\ x'_n \end{pmatrix} + \begin{pmatrix} 0 \\ \vartheta \end{pmatrix}$$
(2) (2) (2)

 $\varepsilon = \gamma \tilde{x}_{n+1}^2 + 2\alpha \tilde{x}_{n+1} \tilde{x}_{n+1}' + \beta \tilde{x}_{n+1}'^2 = \gamma x_{n+1}^2 + 2\alpha x_{n+1} (x_{n+1}' + \vartheta) + \beta (x_{n+1}' + \vartheta)^2$ (4)

$$\Delta \varepsilon = 2\vartheta (\alpha x_{n+1} + \beta x'_{n+1}) + \beta \vartheta^2 \tag{5}$$

$$\Delta \varepsilon = \beta \vartheta^2 = \beta \left(\frac{E_{tot} q E_r L}{(E_{tot}^2 - E_0^2)} \right)^2 \tag{6}$$

WARP – Implemented Gun



WARP – Potential Fields

Electrostatic potential in z-x plane



WARP – Electric Fields



WARP – Electric Fields

Emagnitude in z-x plane

